

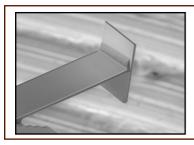
Swiss Nanoscience Institute



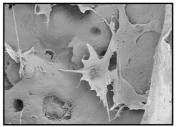
NANO IMAGING LAB

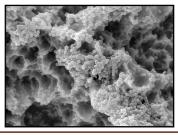
NEWSLETTER

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Welcome to the Nano Imaging Lab (NI Lab) - your new service unit for imaging and illustration of nano structures

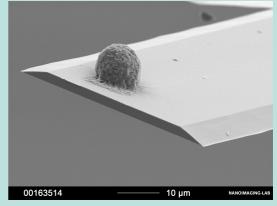


Team of the NI Lab (photo: Christel Moeller)

The NI Lab was founded at the beginning of 2016 and unites members of the former Centre of Microscopy and the Nano Tech Service Lab. We - Evi Bieler, Susanne Erpel, Daniel Mathys, Dr. Monica Schönenberger and the leader of the group Dr. Markus Dürrenberger - possess decades of experience within the illustration of smallest structures. Thanks to our excellent expertise and a varied range of equipment we can deliver optimum service all around the subject Images to customers from the SNI network as well as for external partners. (pricelist)

Nanofabrication

The NI Lab disposes of a scanning electron microscope which is equipped with a focused ion beam (FIB). With this the smallest structures can be worked on. In a cooperation with Professor Edwin Constable of the Department of Chemistry, for example, wafers of solar cells were cut with the FIB and afterwards the layered construction could be examined. For a project of the Professors Christoph Gerber (Department of Physics) and Daniel Müller (D-BSSE) special silicium-cantilevers were produced in precision work of several hours. With these special cantilevers the scientists were capable of fixing single cells and examine the rounding-offprocess of the cell during division.



Cantilever produced by FIB (photo: Daniel Mathys)